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Advanced multilayer development for the water window spectral region

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CHARLES FABRY 2D nanometric multilayer structures

Cr/B₄C alternate multilayer grating for tender X-rays



3 SOLEIL beamlines are now equipped with alternate multilayer gratings !

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EUV/x-ray coatings

2 Magnetron Sputtering (RF/DC, 4 targets) 1 Ion Beam Sputtering (4 targets)





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X-ray microscopy in the water window ($\lambda \approx 3$ nm)

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Primary and secondary mirrors have to be efficient at 3 nm wavelength





CHARLES Cr/Sc reflectance is dominated by interfacial effects

Near-normal incidence interference coating

Best material pair = Cr/Sc (Salashchenko 1994) Period thickness ≈ 1.6 nm Theoretical peak reflectance > 55%





Experimental peak reflectance is severely reduced by interfacial roughness and/or interdiffusion

17.3% - Magnetron sputtered Cr/Sc – F. Shaefers et al., 2003
20.7% - ion-assisted deposition - F. Eriksson et al., 2008
32.1% - B₄C barrier layers - E. Gullikson et al., 2008 unpublished

CHARLES Optimization of Cr/Sc aims at improving the interfaces EUVL 2019

- ✓ Optimization of deposition parameters
 A. Hardouin et al., J. Vac. Sci. Tech. A 2008
- ✓ Study of interfaces
 M. Wu et al., Opt. Eng. 2017
- ✓ Effect of Cr/Sc nitridation

 A. Hardouin, PhD thesis 2007
 C. Burcklen et al., Opt. Lett. 2017
- ✓ Effect of B₄C barrier layer
 C. Burcklen et al., Opt. Lett. 2017



Number of periods = 100

Enhanced reflectance with Cr nitridation and B₄C barrier layer

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Soft X-ray Reflectometry at SOLEIL

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 $CrN/B_4C/Sc$, d = 1.567 nm, 400 periods



C. Burcklen et al., Opt. Lett. (2017)

CHARLES FABRY Drift during deposition is about 0.025 pm/period

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Grazing incidence X-ray Reflectometry at 0.154 nm

 $CrN/B_4C/Sc$, d = 1.567 nm, 400 periods



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CHARLESEffect of period drift on the peak reflectanceFABRY



C. Burcklen et al., Opt. Lett. (2017)

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CHARLES FABRY Can we reach higher reflectance ?

- □ Decrease the period drift < 0.01 pm/period
- Increase the number of periods
- □ Optimize CrN, B₄C and Sc thicknesses

What we need ?

- Accurate (= experimental) values for CrN refractive index
- Analysis techniques with sub-nanometer resolution -> interface properties, N₂ profile





- ✓ Optimization of **deposition process** for new material combinations
- ✓ Physico-chemical properties of sub-nanometric layers and interfaces
- ✓ Accurate knowledge of thin film material **optical constants**



Historical evolution of EUV/x-ray ML structures

- ✓ 2D multilayer structures
- ✓ ultra-short period multilayers
- ✓ Narrowband mirrors
- ✓ Mirrors with enhanced spectral purity

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- Broadband mirrors
- Broadband mirrors with control of the spectral phase